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BY: _____

Lizzy Perkins

SPECIFICATION

To all whom it may concern:

Be It Known, That I, **David M. Weber**, a citizen of United States of America, residing at **3680 Range View Road, Colorado Springs, Colorado 80132**, has invented certain new and useful improvements in "**Automarking, Patternless, Wafer Scale Testing**", of which I declare the following to be a full, clear and exact description:

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BACKGROUND OF THE INVENTION

1. Technical Field:

The present invention is directed generally toward the testing of integrated circuit wafers.

More specifically, the present invention is directed toward testing integrated circuit wafers in parallel using built-in self-test circuitry and self-marking technology.

2. Description of the Related Art:

Integrated circuits (ICs) are typically manufactured in batches on a single disc of material, known as a wafer. One wafer may contain many die (the name commonly given to the individual ICs on a wafer). Environmental and other factors during the manufacturing process may and generally do cause defects in at least some of the circuits on any given wafer. An essential part of the IC manufacturing process, then, is to detect defective ICs and discard them before they are packages for use within a circuit.

Generally, the die on a wafer are tested ("probed") by individually contacting contact pads on each die and executing a variety of functional, fault grade, automatic test pattern generation (ATPG) and parametric tests. If any of the tests fail, then the die is marked as bad. Testing then continues from die to die. For smaller devices, the test time can be acceptably short, and in some cases, the time required to mechanically move the test connection from die to die (mechanical latency) can be the most significant portion of the process. For more complex devices, the test times can be quite large.

What is needed, then, is a test technique that reduces mechanical latency and testing time.

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SUMMARY OF THE INVENTION

The present invention addresses the problem of testing newly-manufactured integrated circuits at the wafer stage. Built-in self-test circuitry is used to test each of the die on a wafer in parallel. Then, when a defect is detected, the die marks itself (e.g., by physically destroying a portion of itself through burnout). The present invention eliminates the inefficiencies of serial testing of die and of mechanical latency as each die is positioned for testing.

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BRIEF DESCRIPTION OF THE DRAWINGS

The novel features believed characteristic of the invention are set forth in the appended claims. The invention itself however, as well as a preferred mode of use, further objects and advantages thereof, will best be understood by reference to the following detailed description of an illustrative embodiment when read in conjunction with the accompanying drawings, wherein:

Figure 1 is a depiction of a semiconductor wafer as it is known in the art;

Figure 2 is a depiction of a wafer prober as it is known in the art;

Figure 3 is a depiction of a sorting device as it is known in the art;

Figure 4 is a diagram of a wafer in accordance with a preferred embodiment of the present invention;

Figure 5 is a diagram of a reticle in accordance with a preferred embodiment of the present invention;

Figure 6 is a diagram of a die in accordance with a preferred embodiment of the present invention;

Figure 7 is a block diagram describing the operation of built-in self-test circuitry in accordance with a preferred embodiment of the present invention;

Figure 8 is a schematic of a linear-feedback shift register used in a preferred embodiment of the present invention;

Figure 9 is a schematic of a multiple input shift register in accordance with a preferred embodiment of the present invention;

Figure 10 is a schematic of a triggering circuit in accordance with a preferred embodiment of the present invention; and

Figure 11 is a block diagram of an alternative embodiment of the present invention utilizing a stored-program embedded computer.

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DETAILED DESCRIPTION

With reference now to the figures and in particular with reference to **Figure 1**, a conventional semiconductor wafer **100** is depicted. Wafer **100** is constructed from a monolithic piece of a semiconductor material, such as silicon, germanium, gallium arsenide, or the like. Wafer **100** contains a number of identical integrated circuits (called die), such as integrated circuit **102**. Each of these integrated circuits will eventually be removed from wafer **100** and packaged for use within a circuit (e.g., on a printed circuit board).

Wafer **100** can be thought of as a "batch" of integrated circuits, analogous to a batch of cookies. A batch of cookies is usually made from a single amount of dough. Yet, as any baker will attest, even cookies made from the same bowl of dough will turn out differently. Some may be overdone, some underdone, some may have more chocolate chips than others. The same goes for a wafer of integrated circuits. Some will be too large in some features, some too small, and some simply will not work at all. The doping of regions may vary within devices on the integrated circuits. The variation of some may fall outside of acceptable tolerances, resulting in unacceptable performance. It is therefore critical that integrated circuits be tested before being packaged for use (which is costly).

Figure 2 is a depiction of a wafer prober (**200**) as it exists in the art. Wafer prober **200** is a testing device used to detect defects in the integrated circuits contained in a wafer. Wafer prober **200** includes a probe card **202**, which contains a number of electrical contacts. Prober assembly **204** holds a wafer in place and positions the wafer under hug **206** of probe card **202** so as to engage the contacts with an integrated circuit on the wafer. Wafer prober **200** then applies a test pattern (a series of signals designed to test particular features of the integrated circuit) to the integrated circuit through the contacts on probe card **202**. The integrated circuit is the monitored through contacts on probe card **202**, so that its behavior may be noted. The observed behavior of the circuit is compared to an expected behavior, and if the two do not match, the integrated circuit is marked as defective. This is usually done by applying a dot of ink to the defective integrated circuit. Prober assembly **204** then repositions the wafer for another integrated circuit to be tested.

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Once wafer prober **200** has identified the defective integrated circuits on the wafer, it is then necessary to sort the defective integrated circuits out of the fully functional integrated circuits. **Figure 3** depicts a sorting device **300**, as present in the art, for carrying out this function. Sorting device **300** contains a robotic assembly **304**, which moves along a track **306**.
 5 Robotic assembly **304** includes both a camera **308** and a manipulator **310**. Camera **308** is used by sorting device **300** to visually spot the defective integrated circuits on wafer **312**. Those circuits that are identified as defective (i.e., by their ink spots) are removed from wafer **312** by manipulator **310** and placed in tray **312**. The remaining circuits are removed by manipulator **310** and placed in tray **314** before moving on the being packaged.

As can be seen, the conventional testing and sorting process depicted in **Figures 2-3** involves two stages in which each integrated circuit on the wafer must be considered individually in sequence. This can be a slow process. It can also be prone to error under circumstances, since the wafer prober must correctly position itself with respect to each individual integrated circuit. A misalignment may result in false test results.

The present invention aims to simplify the process of testing integrated circuits so as to avoid the problems associated with individually testing and inking each defective circuit. The present invention is directed toward testing the integrated circuits on a wafer in parallel and allowing each defective integrated circuit to "mark itself" as defective.

Figure 4 is a diagram depicting a wafer **400** in accordance with a preferred embodiment
 20 of the present invention. Wafer **400** includes an interface point **402**, which allows the entire wafer to be connected to a testing device. Rather than having a wafer prober connect to each individual circuit, wafer **400** allows a testing device to connect through interface point **402**, through signal paths **404**, to each integrated circuit on wafer **400**. Signal paths **404** preferably carry power, a clock signal, and any necessary control signals to the integrated circuits for the
 25 initiation of a built-in self-test (BIST) within each integrated circuit in parallel. Thus, wafer **400** will connect to a testing device through interface point **402**, and the testing device will send power and signals through interface point **402** to initiate self-test procedures by the integrated circuits themselves.

Figure 5 is a magnified view of a reticle **500** of integrated circuits from wafer **400**. A reticle, as commonly used in the art, is a contiguous group of integrated circuits on a wafer that were manufactured simultaneously. One of ordinary skill in the art, however, will appreciate that the invention herein disclosed need not be practiced on a per-reticle basis; the integrated circuits may be tested in groups of any size, including over the entire wafer (perhaps containing many reticles) simultaneously. A reticle is depicted here for the purpose of conveniently displaying a group of integrated circuits.

Each of integrated circuits **501** is connected through connection points **504** to signal paths **502**, which extend around and between integrated circuits **501**. The introduction, by the testing device, of the proper signals in signal paths **502** will initiate a self-test procedure by built-in self-test (BIST) circuitry **602**, shown as part of a further magnified integrated circuit **600** in **Figure 6**. Signal paths **502** may be constructed as part of the normal manufacturing process used to create integrated circuits **501**. For example, signal paths **502** may be constructed as part of a metal layer created during the normal manufacturing process used to make integrated circuits **501**. Also, signal paths **502** may be constructed either on the die themselves, or off the die, on scroll lines, for instance. Scroll lines are lines along which the die are cut from the wafer.

BIST circuitry **602** executes its own test pattern, and if integrated circuit **600** does not respond properly to the test pattern generated by BIST circuitry **602**, visible circuit component **604** will change in appearance (shown turning white in **Figure 5**). Visible circuit component **604** may then be used to identify integrated circuit **600** as defective, rather than an ink dot.

It is important to note at this point that BIST circuitry **602** may comprise any type of built-in circuitry appropriate for the self-testing of a device. It is understood that the phrase "BIST," as used in the art, may carry a narrow meaning with regard to which tests the term represents. This document, however, takes a broad interpretation of the term that encompasses testing techniques of all kinds. The broad interpretation adopted here is more in keeping with the plain meaning of the words "built-in self-test," than that which may be more prevalent within the art.

Visible circuit component **604** is some type of component that can be made to change external appearance. In a preferred embodiment, visible circuit component **604** is a transistor or

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other circuit component that is made to burn out (i.e., a component that is destroyed, and thus changed in appearance, due to overheating; this is typically done by providing too much current to the device). A sufficiently large transistor, when made to burn out due to overcurrent, can be detected by a sorter camera (e.g., camera **308** in **Figure 3**) so that the defective integrated circuit can be disposed of properly. In an alternative embodiment, an internal fuse or array of fuses (such as are used in programmable read-only memory circuits [PROMs]) may be used as visible circuit component **604** and made to blow out when the circuit is defective. One of ordinary skill in the art will recognize that any of a large number of components may be used as visible circuit component **604** without departing from the scope and spirit of the invention. Any circuit component that can change its appearance will do.

Figure 7 is a block diagram describing the operation of built-in self-test circuitry in accordance with a preferred embodiment of the present invention. Pattern generator **700** generates a test pattern to be applied to main circuit **702**, which is under test. In a digital integrated circuit, pattern generator **700** will preferably generate a pseudorandom sequence of bits to apply to main circuit **702**, through the use of a linear feedback shift register (LFSR), for example. Main circuit **702** will, in response to the generated pattern, produce certain results, which are read into results comparator **704**. Results comparator **704** calculates a signature value based on the results of main circuit **702**, through the use of a multi-input signature register (MISR), for example. This signature value acts as a kind of checksum, and results comparator **704** compares its calculated signature value with a pre-calculated signature value **706** to determine whether main circuit **702** is functioning properly. If the calculated signature matches signature value **706**, main circuit **702** is functioning properly. If not, main circuit **702** is faulty. In the event that results comparator **704** determines that main circuit **702** is faulty, results comparator **704** will activate triggering circuit **708**, which modifies the external appearance of the circuit by, for example, blowing a fuse **710**.

Figure 8 is a depiction of a linear-feedback shift register (LFSR) **800** as may be used in a preferred embodiment of the present invention. Input **802** is fed through a series of flip-flops **803**, which are connected in a circular structure by feeding output **804** back into exclusive-or gate **805** into flip-flops **803**. A number of additional connections from output **804**, such as connection

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806 may be made through exclusive-or gates into flip-flops within the series, as shown. LFSR **800** takes a sequence of bits as input and outputs a sequence of bits whose values are a function of the entire sequence of bits fed into LFSR **800**.

To put it simply, LFSR **800** uses feedback to make its current output a function of its entire past. This phenomenon is typically exploited (in cryptography, for instance) so as to make LFSR **800** act as a pseudorandom number generator. An LFSR such as LFSR **800** may be used to produce a pseudorandom test pattern to be applied to the circuit to be tested (i.e., can be used as pattern generator **700** in **Figure 7**).

Figure 9 is a diagram depicting a multiple-input signature register (MISR) **900** that may be used in a preferred embodiment of the present invention. MISR **900** takes multiple inputs **902** and applies feedback to achieve a stream of bits at output **904** that is a function of both current inputs and all past inputs to MISR **900**. This phenomenon allows MISR **900** to be used to calculate a signature (as a series of bits from output **904**) from circuit test results. This signature, being a function of the entire sequence of data input into MISR **900**, can be an effective error-detecting code for detecting discrepancies in the data input into MISR **900**. This signature can then be compared with a reference value (e.g., signature value **706** in **Figure 7**) to detect whether a fault has occurred in the tested circuit.

Figure 10 is a diagram of a triggering circuit that may be used in a preferred embodiment of the present invention to make a visible change to the appearance of the circuit. **Figure 10** is shown implemented in an enhancement-mode metal-oxide semiconductor (MOS) technology, although one of ordinary skill in the art will appreciate that the basic principles depicted in **Figure 10** may be applied to any suitable electronic technology, such as bipolar transistors, junction field-effect transistors, and the like.

Current mirror **1000** is biased by diode-connected transistors **1001** to make transistors **1002** act as current sources providing identical currents. Current mirror **1000** and transistors **1002** are preferably connected to a high-output power supply through the testing device, so as to be able to apply large amounts of current to the visible component to be destroyed (diode-connected transistor **1008**). Transistors **1002** are constructed so as to be able to withstand the amount of current produced by current mirror **1000** through each of transistors **1002**, but the sum

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of the currents provided by transistors **1002** are enough to destroy diode-connected transistor **1008**. Transistors **1004** are under normal operation turned off, so that no current flows through transistors **1002**. When a sufficient voltage is applied at "FRY" input **1006** (from results comparator **704**, for instance), transistors **1004** turn on, and the sum of the currents through
5 transistors **1002** is made to flow through diode-connected transistor **1008**, causing diode-connected transistor **1008** to burn up and leave a visible mark on the integrated circuit. Alternatively, a fuse or other device may be used in place of diode-connected transistor **1008**.

While the embodiments so far presented have focused on the use of "hard-wired" circuitry for determining defects and making visible changes to an integrated circuit, it is also within the spirit and scope of the invention to employ an embedded stored-program computer to execute the testing and marking process. **Figure 11** is a simplified block diagram of an embedded stored-program computer system for testing an integrated circuit. An embedded computer **1100** executes a stored program from memory **1102**. This program includes instructions for generating a test pattern, which is applied to main circuit **1104**. The program also contains instructions for calculating a signature from results of main circuit **1104**. The signature can then be compared by embedded computer **1100** with a signature stored in memory **1102**. The visible component and trigger **1106** may be activated by embedded computer **1100** if the signatures do not match. It is worth noting that if memory **1102** is stored as a programmable read-only memory (PROM), which relies on the use of fuses, memory **1102** may serve as the
15 visible component as well as memory for the stored program, since all (or at least additional ones of the fuses of memory **1102** may be blown in the event that there is no match.

The description of the preferred embodiment of the present invention has been presented for purposes of illustration and description, but is not limited to be exhaustive or limited to the invention in the form disclosed. Many modifications and variations will be apparent to those of
25 ordinary skill in the art. The embodiment was chosen and described in order to best explain the principles of the invention the practical application to enable others of ordinary skill in the art to understand the invention for various embodiments with various modifications as are suited to the particular use contemplated.